

Docket No.: 1806.1003

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Hiroshi YAMADA, et al.

Serial No. 10/514,411

Group Art Unit: 1752

Confirmation No. 4369

Filed: November 15, 2004

Examiner: Connie P. Johnson

For: PHO

PHOTOSENSITIVE RESIN COMPOSITION FOR FORMING A LASER ENGRAVABLE

PRINTING ELEMENT

## **SUBMISSION OF DECLARATION**

Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

Sir:

Examiners Connie Johnson and her supervisor, Ms. Cynthia Kelly, kindly discussed the application with the undersigned on November 8, 2007. The Examiners' time in preparing for and conducting the discussion is acknowledged and gratefully appreciated.

During the discussion, applicants reiterated their position that the references relied upon by the Examiner do not teach or suggest the claimed pore diameter and pore volume. During the discussion, applicants also discussed a Declaration that was filed concurrently with the October 15, 2007 amendment. An unexecuted copy of the Declaration was filed on October 15, 2007. An executed copy of the Declaration is being filed herewith.

Based on the previous amendment and the November 8, 2007 teleconference, it is submitted that the prior art rejections should be withdrawn. There being no other outstanding objections or rejections, it is submitted the application is in condition for allowance. An early action of that effect is courtesly solicited.

Respectfully submitted, STAAS & HALSEY LLP

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